

4728 Gravois Ave. St. Louis, MO 63116 314-832-7726

Fused Silica

DESCRIPTION: Fused Silica offers the same thermal, physical and mechanical properties which are typical of all fused silica. This material is ideal for optical reference flats, test plates, structural members and high temperature view ports where fused silica properties such as low CTE are desired. It is available in substrate and optical (higher homogeneity) grades.

APPLICATIONS: Fused silica can be used where resistance to radiation darkening is required, such as in space or as long-term passive energy collectors.

SHEET SIZES: Up to about 18" x 25" with a wide variety of AVAILABLE THICKNESSES (per quotation).

PROPERTIES:				
<i>Refractive Index</i> n _d (λ = 589 nm) = 1.4584				
Dispersion v = 67.8				
Transmission (estimated at 2 mm thick)		@ 185 nm 88.2%	@ 200 nm 89.4%	@ 230 nm 91.1%
		@ 310 nm 92%	-	400-1240 nm 92%+
		Transmittance at varying levels from 1250 nm to 4400 nm		
Bubble Inclusion Class No. 0 upon request		(Max. cross-section of any single bubble or inclusion = 0.004")		
		(Total cross-section of inclusions/100 cm ³ = 0.03 mm^2)		
Homogeneity Substrate Grade: Not specified				
Optical Grade F: 5 x 10 ⁻⁶ (higher grades available on request)				
Thermal CTE (0 - 200°C): 5.7 x 10 ⁻⁷ /°C				
Thermal Conductivity (25°C): 1.38 W/m°C				
Specific Heat (25°C): 0.177 cal/gm°C				
Thermal Diffusivity (25°C): 8.4 x 10 ⁻³ cm ² /sec.				
Electrical Dielectric Constant (25°C, 1 KHz): 3		3.79 Dielectrie	Dielectric Loss Factor (25°C, 1 KHz): 0.00002	
Physical				
Density	Softening Point Strain	Point Annealing	g Point Elastic	c (Young's) Modulus
2.202 g/cm ²	³ 1585°C 990	0°C 1075	°C 7.3 ×	: 104 M Pa @25℃